## **IN THE CLAIMS**

The following is a complete listing of the claims which replace any prior versions:

1	1-39. (Canceled)
1 ·	40. (New) A method for providing precise control of a magnetic coupling field in
2	a NiMn top spin valve head, comprising:
3	forming a copper seed layer on a substrate;
4	forming a free layer on the copper seed layer;
5	forming a non-ferromagnetic layer on the free layer;
6	forming a copper spacer layer on the non-ferromagnetic layer;
7	forming a pinned ferromagnetic layer on the copper spacer layer; and
8	forming a NiMn pinning layer over the pinned ferromagnetic layer;
9	wherein the copper seed layer and copper spacer layer are oxidized separately during
10	formation
1	41. (New) The method of claim 40, wherein the forming the copper seed layer
2	comprises depositing a layer of copper as a seed layer and, before depositing a next layer,
3	oxidizing the copper seed layer.
1	42. (New) The method of claim 41, wherein the forming the copper spacer layer
2	comprises depositing a layer of copper as a spacer layer and, before depositing a next layer,
3	oxidizing the copper spacer layer.

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- 1 43. (New) The method of claim 40, wherein the forming the copper spacer layer
- 2 comprises depositing a layer of copper as a spacer layer and, before depositing a next layer,
- 3 oxidizing the copper spacer layer.
- 1 44. (New) The method of claim 40, wherein the copper seed layer and oxidized
- 2 spacer layer are naturally oxidized for 80 seconds under 8 x 10-5 Torr of oxygen pressure.
- 1 45. (New) The method of claim 40, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer reduce the ferromagnetic coupling field without deteriorating GMR
- 3 effect or resistance.
- 1 46. (New) The method of claim 40, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer provide a negative coupling field without affecting GMR effect or
- 3 resistance.
- 1 47. (New) The method of claim 40, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer change the crystalline texture growth of subsequent layers.
- 1 48. (New) The method of claim 40, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer provide a negative coupling field that is achieved without affecting a
- 3 GMR effect or resistance of the NiMn top spin valve head.
- 1 49. (New) The method of claim 48, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer provide stronger growth of NiFe(111) and NiMn(111) with respect to
- 3 NiFe(200) and NiMn(002) phases.

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- 1 50. (New) The method of claim 40, wherein the oxidized copper seed layer and
- 2 oxidized spacer layer improve the interfacial roughness.
- 1 51. (New) The method of claim 40, wherein the oxidation of the copper seed
- 2 layer and spacer layer does not affect asymmetry performance.